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# Nanoscale Chemical Analysis in Various Interfaces with Energy Dispersive X-Ray Spectroscopy and Transmission Electron Microscopy

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## 1. Introduction

The properties of materials strongly depend on their microstructure such factors as lattice defect type and density, size, distribution of phases present. During last half century, the development of transmission electron microscopy (TEM) has provided an advance in our understanding of the details of not only the microstructure but also the crystallographic feature of materials on a sub-micrometer scale (Edington, 1974; Fultz & Howe, 2002; Williams and Carter, 1996). On the other hand, many of materials generally consist of more than two elements and include impurities and those are applied to the industrial field. Abovementioned lattice defects in those alloys are one of preferential site of segregation of alloying elements and impurities. In order to clarify the mechanical and functional behaviors of the alloys, we should investigate not only the microstructure but also the elemental distribution of alloying elements and impurities. For latter purpose, TEM equipped with a spectroscope is considered to be one of powerful tool. Typical spectroscopes installed to TEM are energy dispersive X-ray spectroscopy (EDS), wavelength dispersive X-ray spectroscopy (WDS) and electron energy loss spectroscopy (EELS). These spectroscopes are utilized some signals resulting from an interaction between electron and specimen as shown in Fig. 1. For EDS, characteristic X-ray shown as red colored characters in Fig. 1 is analyzed. In this chapter, the EDS is focused. EELS is also one of important spectroscopy in TEM as well as EDS. The EELS is detected and analyzed an inelastic electron interacted with the specimen. EELS has an advantage for analysis of light elements such as B, C, N and O. Additionally, obtained EEL spectrum provides the chemical bonding information of the specimen. Details can be referred to some references (Brydson, 2001; Egerton, 1996). EDS combined with TEM is one of useful spectroscopy in the materials science and widely used for chemical analysis such as identification and composition of the elements in desirable region on a submicrometer scale. Especially, the field emission (FE) type electron source in the electron gun of TEM has been developed recently, and it has been enabled to analyze the chemical composition on a nanoscale, since the electron probe size with the FE type electron gun can be easily converged to less than 1nm compared with conventional thermal filament type electron gun such as tungsten (W) and lanthanum hexaboride (LaB<sub>6</sub>). So far, we had investigated the chemical analysis around the interface

and surface in some materials and composite by using TEM with FE type gun. In this chapter, principles of EDS will be overviewed briefly and the validity of the analytical technique with the results for metal/ceramic clad materials and zirconia ceramics focused on their interfaces such as bonding interface, surface of the particles and interphase boundary are shown.

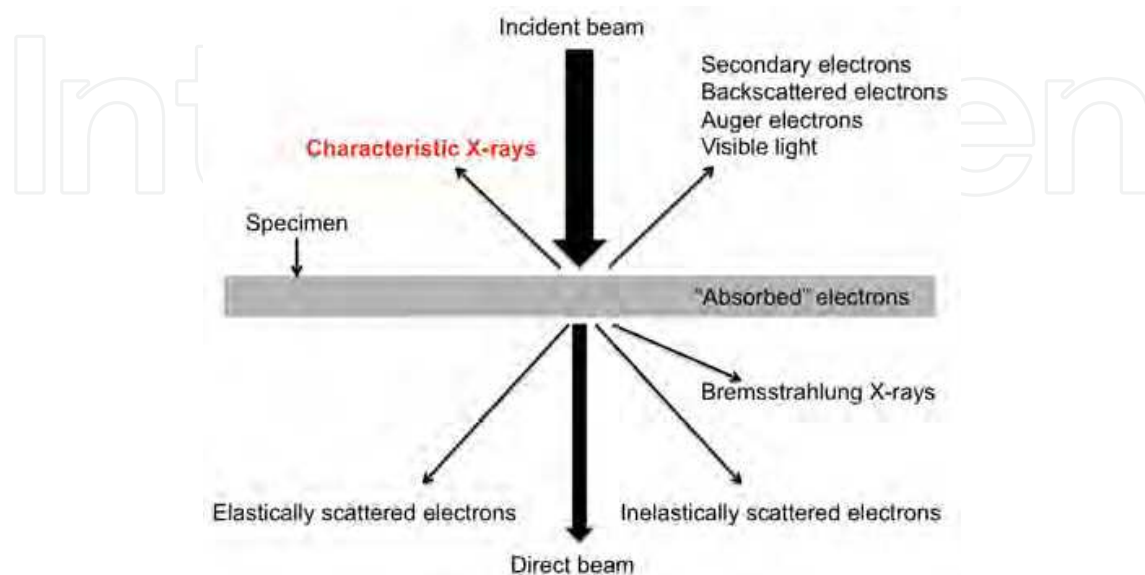


Fig. 1. An interaction of a high voltage electrons and specimen. For a qualitative and quantitative analysis with EDS, characteristic X-rays shown as bold are used.

## 2. Principles of energy dispersive X-ray spectroscopy

When high voltage electrons traverse a thin foil specimen, one of the primary inelastic interactions is that of inner-shell, ionization as shown in Fig. 2. The ejection of a K-shell electron leaves the atom in an excited state. One of the ways that it can return to ground is by an electron from an outer shell falling to the vacant inner-shell position and at the same time emitting an X-ray of characteristic energy as well as wavelength. This characteristic energy is a function of the difference in electron energy levels of the atom. Thus, it is these X-rays, which we are interested in because they provide direct information about the chemistry of the interaction between the electron and beam. In usual measurement of the EDS, a continuous X-ray is detected as well as characteristic X-rays. The continuous X-ray is emitted with Bremsstrahlung, which is caused by the interaction of the electron beam and a nucleus. In that case, the energy of the incident electrons is changed with the interaction and the extra energy is emitted as a photon. That photon is detected as the continuous X-ray. The continuous X-ray is usually seen as background in the X-ray spectrum. Fig. 3 is the typical EDS profile taken from yttria ( $Y_2O_3$ ) doped zirconia ( $ZrO_2$ ), which detail is shown later. Generally, for detection of the characteristic X-ray, silicon-lithium (Si(Li)) semiconductor detectors are used in almost all TEM-EDS as shown in Fig. 4. And they are sealed with different kinds of window consisting of beryllium or an ultrathin polymer to reduce a contamination with hydrocarbons and water vapor from the TEM. And a windowless detector is also used. The ultrathin window and windowless detector can detect the light elements such as B, C, N and O. However, the usual EDS detectors have a disadvantage of relative poor energy resolution, which is approximately 130-140keV in the case of the

conventional Si(Li) type detector. In order to overcome this problem, EDS with a microcalorimeter detector has been developed (Hara et al., 2010), which a superconducting transition-edge-sensor type microcalorimeter is employed as the new detector. This new EDS system will enable to detect with much higher energy resolution of 20eV compared

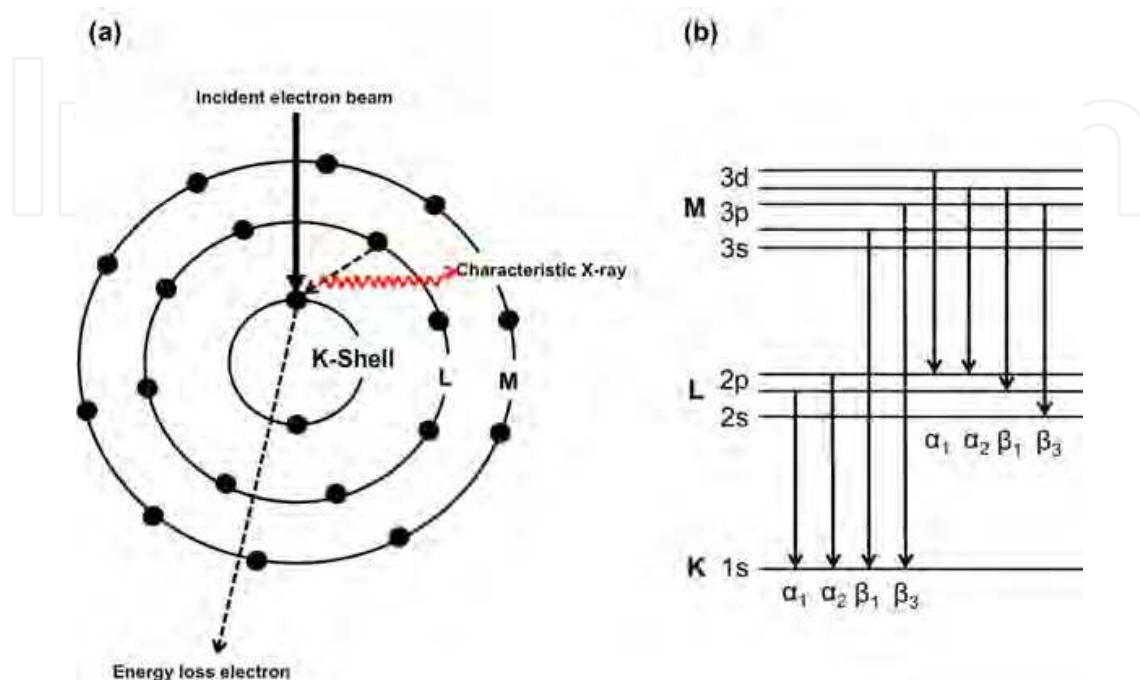


Fig. 2. (a) A schematic illustration of the mechanism of the characteristic X-rays generation. In this illustration, the generated characteristic X-ray corresponds  $K\alpha$  X-ray. (b) A relationship between the kind of characteristic X-ray and energy level of electrons.

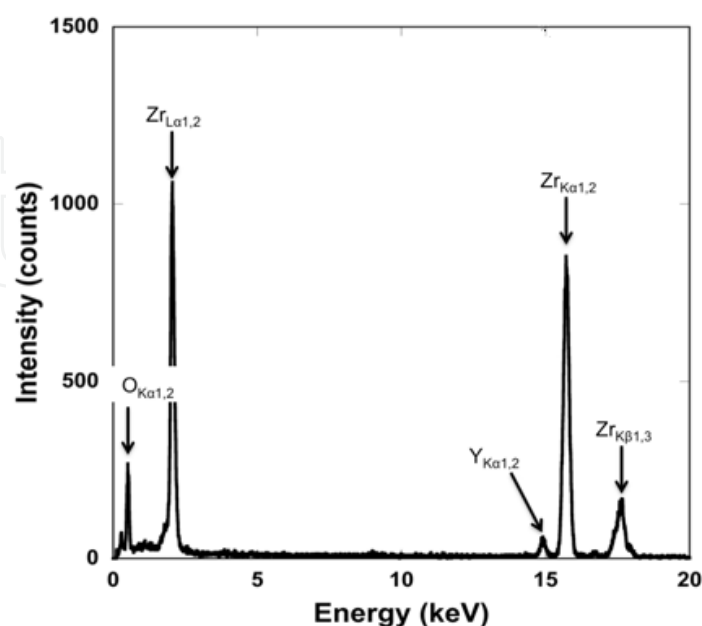


Fig. 3. Typical EDS profile obtained from  $Y_2O_3$  doped  $ZrO_2$ .

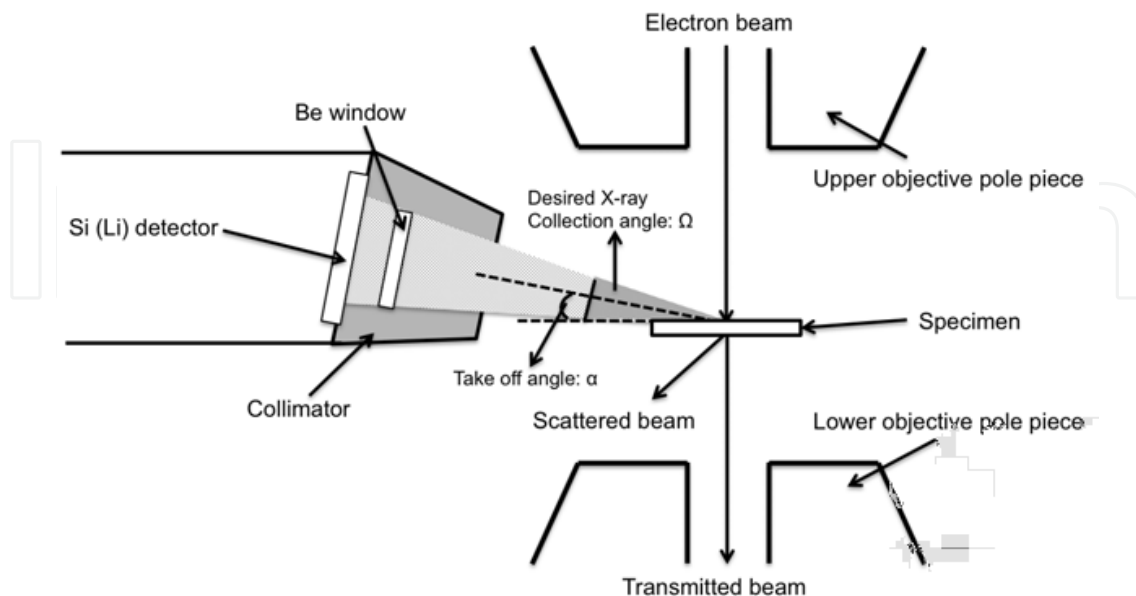


Fig. 4. A schematic drawing of a cross section of EDS detector and objective lens in TEM stage.

with the conventional Si(Li) type detector. Moreover, its detection limit will be improved because of the high sensitivity. As above mentioned, electron beam is interacted with nucleus and electrons of atoms. The behaviors of the interaction in a matter, we can predict with Monte Carlo method. Usually, the extent of the electrons depends of the mass of the matter, i.e., atomic number and is wider with increasing of the atomic number. The extent of the electron is defined as a spatial resolution, which is shown as following equation:

$$b = b_0 + 6.25 \times 10^4 \times \left( \frac{Z}{E_0} \right) \times \left( \frac{\rho}{A} \right)^{1/2} \times t^{3/2} \quad (1)$$

here,  $b_0$  is incident electron probe size,  $Z$  is atomic number,  $E_0$  is acceleration voltage,  $\rho$  is density of specimen,  $A$  is mass number and  $t$  is thickness of the specimen, respectively.

By using above equation, spatial resolution of 0.5 to 1 nm can be obtained in TEM with FEG. Most important thing to efficiently detect the X-ray in TEM-EDS is large solid angle  $\Omega$  shown in Fig. 3, which is schematic illustration of TEM-EDS system and high current density. The solid angle is explained as equation (2),

$$\Omega = \frac{S}{L^2} \quad (2)$$

here,  $S$  is cross section of the detector and  $L$  is distance between the specimen and the detector, respectively. As shown in eq. (2), the detector should be designed near the

specimen. Recently, the EDS detector in TEM is designed as semi high angle side type. This type detector is well balanced between resolution of image and X-ray detection efficiency. To improve the X-ray detection efficiency, the specimen holder is also devised as well as design of the TEM-EDS instrument.

Quantitative X-ray analysis in the TEM-EDS is one of most straightforward technique. Usual quantitative analysis is used standard sample, which its composition has been already known. And both X-ray intensities in spectra obtained from standard and unknown specimen are compared to each other and quantitative values are estimated. However, since the absorption and fluorescence effect in thin film specimen is less than that in bulk specimen, most of the quantitative analyses in TEM are performed without the measurement of the standard sample and calculated from relative intensity of experimentally obtained each peaks corrected atomic number ( $Z$ ), absorption ( $A$ ) and fluorescence ( $F$ ). Therefore, its analytical method is referred as ZAF (or standardless) method. That is, even if the X-ray correction is simplified, quantitative analysis has been done with high accuracy. In the case of thin film, which thickness is less than several 10 nm, the intensity  $I_A$  of characteristic X-ray emitted from specimen A is described as,

$$I_A = (I\sigma_A\omega_A a_A N_0 \rho_A C_A \Omega \varepsilon t) / M_A \quad (3)$$

here,  $I$  is the intensity of the incident beam,  $\sigma$  is ionized cross section of K (or L, M)-shell,  $\omega$  is fluorescence efficiency,  $a$  is intensity ratio of K (or L, M) peak for all K (or M, L) shell,  $N_0$  is Avogadro number,  $\rho$  is density,  $C$  is atomic composition,  $\Omega$  is solid angle,  $\varepsilon$  is detection efficiency,  $t$  is thick ness of the specimen and  $M$  is atomic weight, respectively.  $\sigma_a$  of K-shell is known as follows:

$$\sigma_A = 4\pi a_0 N_k b_k (R / E_0)(R / E_k) \ln(c_k E_0 / E_k) \quad (4)$$

, which  $a_0$  is Bohr radius,  $N_k$  is the number of electrons in K-shell,  $E_0$  is the energy of electrons,  $E_k$  is the ionization energy of K-shell,  $b_k$  and  $c_k$  are constant and  $R$  is Rydberg constant, respectively.

Additionally, the fluorescence efficiency  $\omega$  is also expressed as

$$\omega = Z^4 / (b_k + Z^4) \quad (5)$$

in which,  $Z$  is the atomic number. By using above equations (3) to (5), the characteristic X-ray ratio from element A and B is represented as:

$$\frac{I_A}{I_B} = \frac{(\sigma_A \omega_A a_A \rho_A C_A) \cdot M_B}{(\sigma_B \omega_B a_B \rho_B C_B) \cdot M_A} \quad (6)$$

Therefore, between composition and intensity of the X-ray in element A and B is related as follows:

$$\frac{C_A}{C_B} = \frac{(\sigma_B \omega_B a_B \rho_B) \cdot M_A \cdot I_A}{(\sigma_A \omega_A a_A \rho_A) \cdot M_B \cdot I_B} = k_{A,B} \left( \frac{I_A}{I_B} \right) \quad (7)$$

In this equation,  $k_{A,B}$  is known as k factor or Cliff-Lorimer factor and composition ratio strongly depends on the k-factor in the experimental EDS measurement. Since the k-factor is

also closely related to the specimen and EDS apparatus, therefore it is quite important to clarify the k-factor with high accuracy in the quantitative EDS analysis. This k-factor is changed daily in actual EDS measurement, because of the different acquirement condition, so that it should be measured for accurate measurement. And in the case of relative thick specimen, absorption correction should be considered. Horita et al., have been proposed k-factor with considering of absorption correction, and they have shown its effectivity (Horita et al., 1998).

### 3. Experimental chemical analysis with TEM-EDS for elemental distribution

#### 3.1 Chemical analysis in bonding interface of explosively welded metal/ceramic clad materials

Explosive welding technique is one of solid-state welding and clad materials fabricated by this technique have high reliability of the bonding strength (Crossland, 1982). This technique was developed in the 1950s for joining metallic plates. It has been widely used for industry due to its advantage of direct bonding without bonding medium such as braze so far. Nowadays, an application of the explosive welding technique is extended to the field of composite which ductile metals are joined onto brittle materials such as ceramics and metallic glasses as well as metal/metal clad. However, during explosive welding with high-speed deformation, many cracks are introduced and propagated into the brittle materials and it is serious problem. To overcome that problem, Hokamoto et al. have attempted the metal/brittle materials such as ceramic and metallic glass clad consisted of a metallic foil onto brittle material plate by explosive welding (Hokamoto et al., 1998, 1999, 2010). Especially, they have succeeded the fabrication of metal/ceramics clad materials of several 10 mm without cracks by regulated underwater shockwave (Hokamoto et al., 1998, 1999). In order to understand the bonding mechanism and welding process, it is a key to clarify the bonding interface in the clad. In this chapter, the observation result of the bonding interface between aluminum (Al) and silicon nitride ( $\text{Si}_3\text{N}_4$ ) clad material with explosive welding by TEM. And based on the chemical analysis in bonding interface measured by EDS with TEM, the bonding mechanism is also discussed (Ii et al., 2010). Fig. 5 is an external view of explosively welded Al/ $\text{Si}_3\text{N}_4$  clad. In this experiment, Al of a flyer plate is welded onto  $\text{Si}_3\text{N}_4$  as a base material. Al is locally deformed, but Al and  $\text{Si}_3\text{N}_4$  are macroscopically well bonded without macroscopic cracks in both materials. The bright field image around the bonding interface of the clad material is shown in fig. 6. There are also no microscopic cracks around the interface and fine grained layer between Al and  $\text{Si}_3\text{N}_4$  indicated as intermediate layer in the center of fig. 6. The width of the intermediate layer is approximately  $2.5\mu\text{m}$ . The selected area electron diffraction pattern taken from the region included this intermediate layer is mainly consisted of Debye-Scherrer ring pattern, which is often seen in fine grained polycrystalline. This pattern is also explained without inconsistency, by using the lattice parameter of Al. Therefore, it can be expected that the intermediate layer consist of nanocrystalline Al. In order to clarify the components of the intermediate layer from the chemical viewpoint, EDS measurement and qualification analysis around the interface are performed with scanning TEM (STEM). Although STEM is a type of the TEM, the electron beam of TEM in most of the observations is usually parallel without any convergence. On the other hand, that of the STEM is.

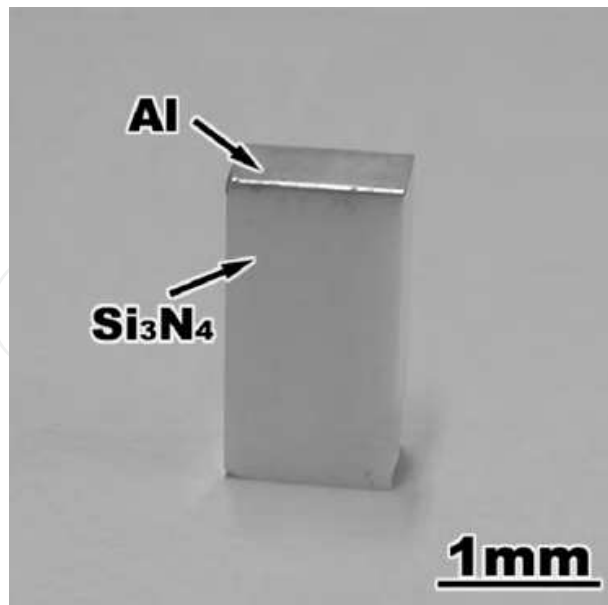


Fig. 5. An outer view of the explosively welded Al/Si<sub>3</sub>N<sub>4</sub> clad. In this figure, upper Al as flyer plate is bonded onto Si<sub>3</sub>N<sub>4</sub> base material during explosive welding. And no macroscopic cracks are observed.

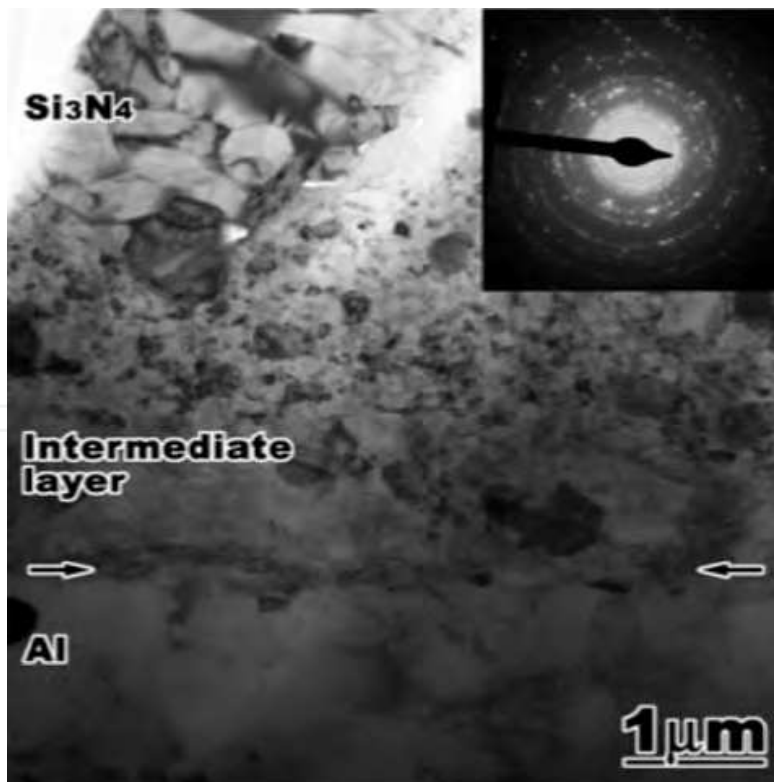


Fig. 6. A Bright field image of the interface of Al/Si<sub>3</sub>N<sub>4</sub> clad. A selected area electron diffraction pattern is inserted on the top-right of the image. At the center in this figure, the intermediate layer consisting of a nanocrystalline grain is clearly seen.



illuminated to the specimen with large convergence angle the specimen and scanned in a desirable raster. And the STEM is imaged by the detection of the scattered electron. The detectors in STEM are set to detect the specific scattered electron. Details of STEM are described in elsewhere (Pennycook & Nellist, 2011). Fig. 7 shows the STEM bright field image and the intermediate layer was also clearly observed in fig. 7. Fig. 8 shows X-ray intensity profile across the interface in the Al/Si<sub>3</sub>N<sub>4</sub> clad material obtained by EDS line analysis along the line shown in Fig. 7. Black and red lines correspond to the X-ray intensity of Al-K $\alpha$  and Si-K $\alpha$ , respectively. In this figure, the X-ray intensity of the Al-K $\alpha$  peak is increasing with increase of the distance in fig. 8. Both X-ray intensities of each element are drastically changed at the 0.8 $\mu$ m in this figure, where approximately corresponds to the interface between Si<sub>3</sub>N<sub>4</sub> and nanocrystalline region in the fig.6 and 7. The EDS line profile show that the nanocrystalline region consist of only Al. Many researchers have been reported microstructure around the interface the explosively welded clad materials (Dor-Ram et al., 1979; Kreye et al., 1976; Murdie & Blankenburgs, 1966; Nishida et al., 1993, 1995), so far. Among them, Nishida et al. have precisely investigated the interface of an explosively welded Ti/Ti clad by TEM and found the almost same structure consisting of fine grains. They concluded that the nanocrystallization is caused by the rapid solidification of a thin molten layer formed during the welding (Nishida et al., 1993). In this observation, nanocrystalline region consisting of only Al are also observed. Additionally, melting point of Al is much lower than that of Si<sub>3</sub>N<sub>4</sub>, and Al and Si are not solute to each other judging from Al-Si binary equilibrium phase diagram (Murray & McAlister, 1990). Therefore, it can be concluded that nanocrystalline layer is formed with rapid solidification of Al during the explosive welding.



Fig. 7. A STEM image of the interface of Al/Si<sub>3</sub>N<sub>4</sub> clad. EDS line profile shown in Figure 8 was measured along the black line in this figure.

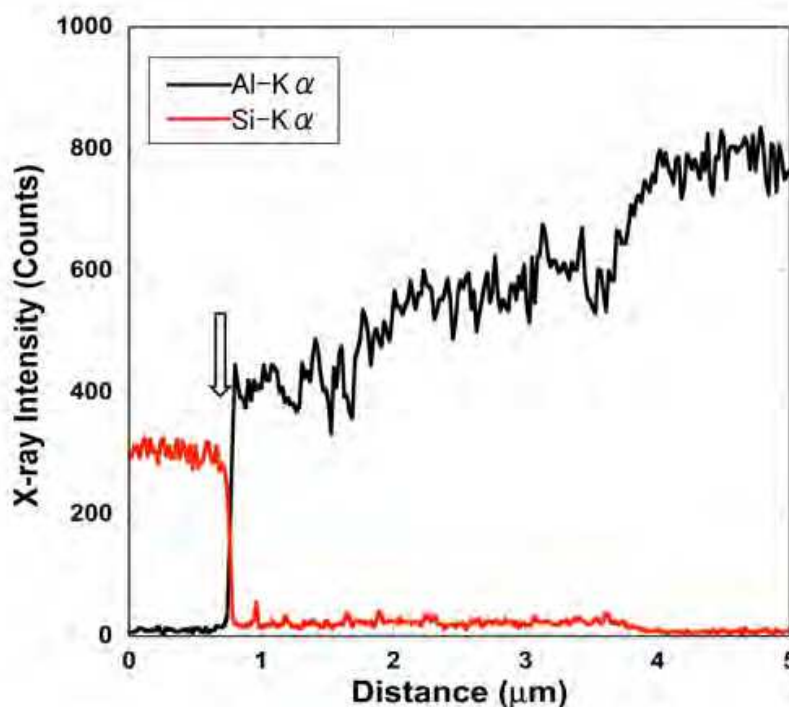


Fig. 8. X-ray intensity profiles of Al-K $\alpha$  (Black line) and Si-K $\alpha$  (Red line). Each X-ray intensities are drastically changed at the point shown as arrow. From our systematic analysis, the interface in this clad corresponds to the position where the X-ray intensities are steeply changed.

### 3.2 Quantitative analysis of surface segregation in Y<sub>2</sub>O<sub>3</sub> doped ZrO<sub>2</sub> nano particles

Yttria-stabilized tetragonal zirconia polycrystal (Y-TZP) has proved to be one of important structural ceramic with excellent mechanical properties such as high fracture toughness, strength, and hardness (Gravie et al., 1975; Green et al., 1989). The microstructure and grain growth behavior in sintered bulk Y-TZP have been extensively investigated so far (Ikuhara et al., 1997; Lange, 1988; Lee & Chen, 1988; Sakuma & Yoshizawa, 1992; Yoshizawa & Sakuma, 1989). It has been known that fine grained Y-TZP with the grain size of submicrometer can be obtained because of the formation of cubic and tetragonal two-phase composites. In this case, the tetragonal-cubic phase separation is considered to take place during sintering, and therefore fine grained structure results in stable Y-TZP. In addition, raw ZrO<sub>2</sub> powders with nano-order grain size and good sinterability are commercially available. High-quality Y-TZP powders with narrow particle size distribution can be obtained by the hydrolysis process (Matsui et al., 2002). In previous paper, the microstructural development of the Y-TZP during sintering was investigated by transmission electron microscopy (TEM) observations and energy-dispersive X-ray spectroscopy (EDS) analyses (Matsui et al., 2003), and it was revealed that the yttrium cations tend to segregate in the vicinity of grain boundaries. The relationship between the microstructure of sintered body and the properties of the raw powders have been examined, and it has been pointed out that the microstructure and physical properties of the sintered body strongly depend on the properties of raw powders (Hishinuma et al., 1988). It is therefore crucial to clarify the microstructure and local composition of the

starting powders. In order to clarify whole of the particles on a nano scale, the specimen preparation technique for the high resolution electron microscopy observation has been developed (Ii et al., 2006). In this section, the results of the microstructure and  $Y^{3+}$  cation distribution of the  $Y_2O_3$  doped  $ZrO_2$  particles by high-resolution TEM (HRTEM) observations and EDS measurements are shown. Figure 9 (a) shows a typical high-resolution electron micrograph of the yttria-doped zirconia particle. First Fourier Transformed (FFT) pattern of the powder is shown as an inset at the lower-left side in the micrograph. The FFT pattern corresponds to the electron diffraction pattern taken from  $[01\bar{1}]$  of the tetragonal phase and it indicates that the particle is tetragonal single phase. Fig. 9 (b) and (c) show an enlarged lattice image of the surface and internal region as indicated by B and C in (a), respectively. As shown in Figs. 9 (b) and (c), the two-dimensional lattice fringe is clearly observed inside the particle. Figure 10 shows the composition of  $Y_2O_3$  analyzed from EDS spectra as a function of distance from the surface of the particle. The error bars to each measuring point are also shown. In this EDS measurements, the spectra obtained from this particle and the quantitative analysis have high reliability, because the thickness of the specimen is thin enough to obtain the lattice image into the internal region and uniform. In Fig. 10, the error is within 0.3% of each estimated value, and it is relatively small compared with the estimated  $Y_2O_3$  composition. Both the  $Y_2O_3$  compositions take on the maximum value at the surface of the particle, but suddenly reduce at a distance of 1 nm off from the surface. The  $Y_2O_3$  composition increases again with increasing distance from the surface, but takes on a constant value over the distance of 5 nm. This fact suggests that  $Y^{3+}$  cations migrate from 1 nm inside to the surface of the particle and segregate at the surface.

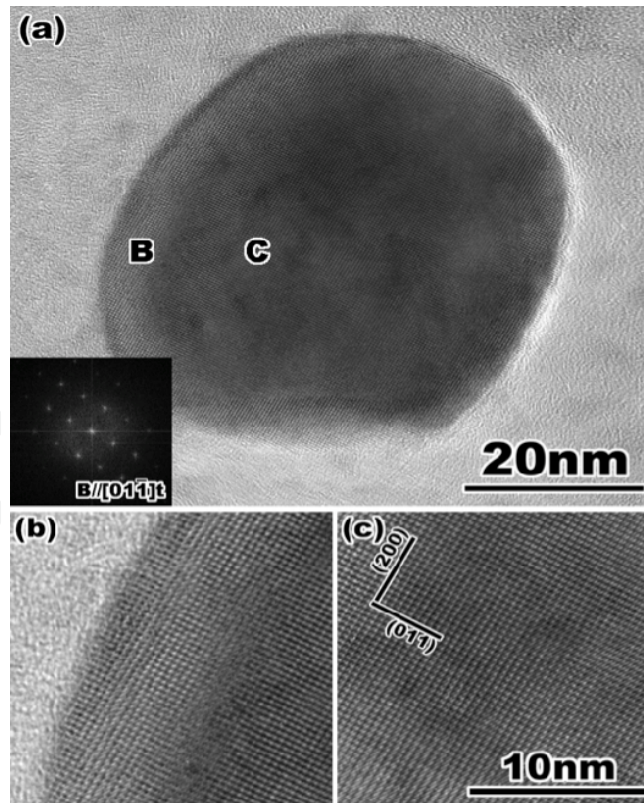


Fig. 9. (a) A high resolution TEM image of  $Y_2O_3$  doped  $ZrO_2$  particle. The FFT pattern in (a) indicates that the particle is tetragonal single phase. (b) and (c) Enlarged lattice image of the surface and the internal region of the particle indicated by B and C in (a), respectively.

In the case of grain boundary in polycrystalline  $\text{Y}_2\text{O}_3$  doped  $\text{ZrO}_2$ , dopant cations have been reported to segregate at the vicinity of the grain boundary over the width of several nm to reduce excess grain boundary energy (Ikuhara et al., 1997; Shibata et al., 2004). The present results are obtained in a situation such that the surface excess energy is reduced by surface segregation of the  $\text{Y}^{3+}$  cations. The observation of the other particles also showed almost same tendency. On the other hand, some of the particles, which the tetragonal phase transforms to the monoclinic phase, have a uniform distribution of  $\text{Y}_2\text{O}_3$  contents, and that the formation of monoclinic phase is not attributed to  $\text{Y}_2\text{O}_3$  inhomogeneous distribution. The stability of the monoclinic phase of  $\text{ZrO}_2$  has been reported to depend on the grain size; the tetragonal phase of  $\text{ZrO}_2$  with the grain size of less than 500 nm cannot be thermally transformed to monoclinic phase (Gupta et al., 1978; Sakamoto, 1990). Since the average size of the present zirconia particle is approximately 50 nm, the formation of monoclinic zirconia cannot be explained from a thermomechanical point of view. Moreover, the monoclinic phase was observed in the vicinity of the surface. Therefore, the monoclinic phase is probably formed by stress-induced transformation during the milling process, which was performed in the final stage of the powder fabrication.

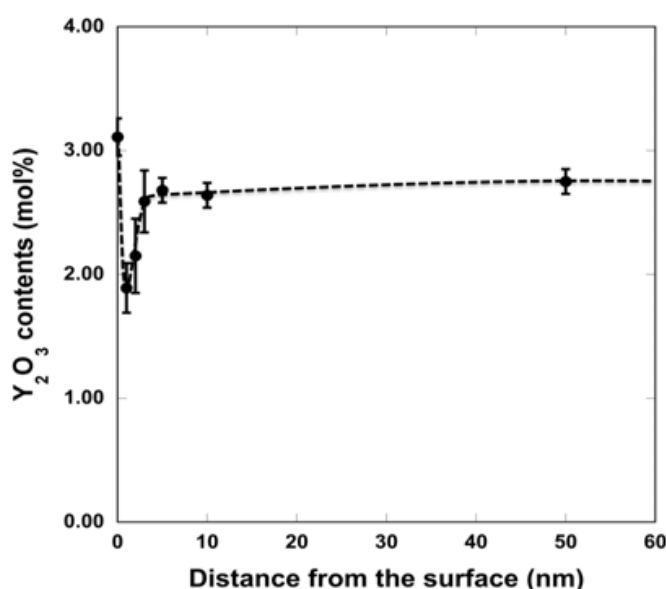


Fig. 10. A composition of  $\text{Y}_2\text{O}_3$  estimated by quantitative analysis of EDS spectra in  $\text{Y}_2\text{O}_3$  doped  $\text{ZrO}_2$  particle as a function of the distance from the surface.

### 3.3 Yttrium cation distribution at cubic and tetragonal interphase boundary in Y-TZP

As abovementioned,  $\text{Y}_2\text{O}_3$  stabilized tetragonal  $\text{ZrO}_2$  polycrystal (Y-TZP) is one of the technologically important structural ceramics. For the development of the Y-TZP bulk materials, the microstructural development including phase transformation and grain growth in Y-TZP has been widely investigated by many researchers so far (Gravie et al., 1975; Lange, 1988; Lee & Chen, 1988; Yoshizawa & Sakuma, 1989). Their most important aspects of the relationship between the phase transformation and grain growth were that grain growth in the tetragonal (t) and cubic (c) dual-phase region is slower than t or c single phase region. For instance, the grain growth behavior in 4mol%  $\text{Y}_2\text{O}_3$ -stabilized  $\text{ZrO}_2$  was explained in terms of the pinning-effect of cubic phase grains dispersed in TZP (Yoshizawa & Sakuma, 1989). However, it should be noted that their phenomenological analysis was

based on the assumption that the  $\text{ZrO}_2\text{-Y}_2\text{O}_3$  in t and c two-phase region was dual-phase composite consisting of t- and c-grains. On the other hand, Ikumura *et al.* (1997) investigated the microstructure in TZP by high resolution transmission electron microscopy (HRTEM) and energy dispersed x-ray spectroscopy (EDS), and found that  $\text{Y}^{3+}$  cations are segregated over a width of 4-6 nm across the boundaries in TZP. More recently, the detailed microstructural change during sintering process in TZP has been investigated and a formation of the cubic phase from grain boundary due to the  $\text{Y}^{3+}$  cation's segregation and its growing to the grain interior are found (Matsui *et al.*, 2003, 2006). Thus, this tetragonal to cubic phase transformation is termed as grain boundary segregation induced phase transformation (GBSIPT). Through the GBSIPT, the interphase boundary between the front of the cubic phase and the tetragonal matrix, i.e. c/t interphase boundary is likely to form inside grains. The lattice parameter ratio is slightly different between tetragonal and cubic phases, whose lattice mismatch of two phases is less than 1%. Therefore, it can be expected that the interphase boundary is coherent or semi-coherent boundary. In the case of the semi-coherent boundary, the excess strain interface energy is released by introducing misfit dislocation. In this section, the relationship between the interphase boundary structure and yttrium cation distribution in Y-TZP is focused. Fig. 11 (a) shows a typical microstructure observed in the Y-TZP specimen sintered at  $1650^\circ\text{C}$ . As shown in Fig. 11 (a), the dot-like contrasts between two arrows are periodically observed inside the grain.

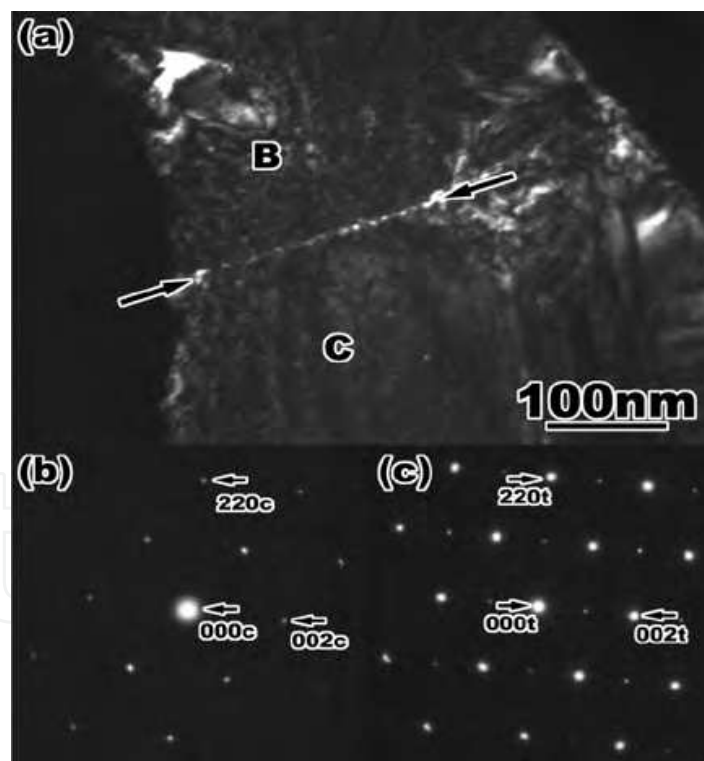


Fig. 11. (a) A Dark field image of typical microstructure of sintered  $\text{Y}_2\text{O}_3$  stabilized  $\text{ZrO}_2$  tetragonal zirconia polycrystal. This image were slightly tilted to keep the two beam excitation condition with  $g = (110)_{c,t}$  and see misfit dislocations clearly. (b) and (c) Selected area electron diffraction patterns taken from B and C indicated in (a). The incident electron beam direction is parallel to  $[1\bar{1}0]_{c,t}$ . And these diffraction patterns show cubic in (b) and tetragonal (c) single phase, respectively.

Fig. 11 (b) and (c) show selected electron diffraction patterns taken from the region marked by B and C in Fig. 11 (a), which indicates the interface is formed between cubic (Fig. 11 (b)) and tetragonal (Fig. 11 (c)) phase, respectively. Therefore, we considered that their dot-like contrasts are on the interface. The average interval of these contrasts is estimated to be approximately 10 nm. An arrangement of the periodic contrast was confirmed to be close to near  $\langle 111 \rangle$  direction from the result of the trace analysis in the obtained TEM micrograph and electron diffraction patterns. In addition, it was also confirmed that the plane normal of this interface, which is the periodic contrast along near  $\langle 111 \rangle$  direction, is close to the  $\langle 22\bar{1} \rangle_t$  and  $c$ , respectively. Consequently, it is predicted that the interphase boundary observed in this specimen is near  $\{22\bar{1}\}_t$  and  $\{22\bar{1}\}_c$ , respectively. In order to investigate the detailed interphase boundary structure, especially misfit dislocation structure on an atomic level, HRTEM observations for the c/t interphase boundary have been done and revealed that the misfit dislocations at the c/t interphase boundary are clearly observed (Li et al., 2008). Fig. 12 shows the profile of the  $Y_2O_3$  contents from EDS spectra as a function of distance from the c/t interphase boundary in Y-TZP. The  $Y_2O_3$  contents take the uniform value both in the cubic and tetragonal regions, but steeply changes across the c/t interphase boundary. The steeply sloped change in the  $Y_2O_3$  contents is in good agreement with the fact that the misfit dislocations are introduced by the difference in the lattice parameter between c and t phases with different  $Y^{3+}$  compositions. It should be noted that the yttrium distribution is almost uniform inside the grain in the bulk Y-TZP sintered at 1300°C. The present results indicate that  $Y^{3+}$  cation redistribution takes place in association with tetragonal-cubic phase transformation in Y-TZP.

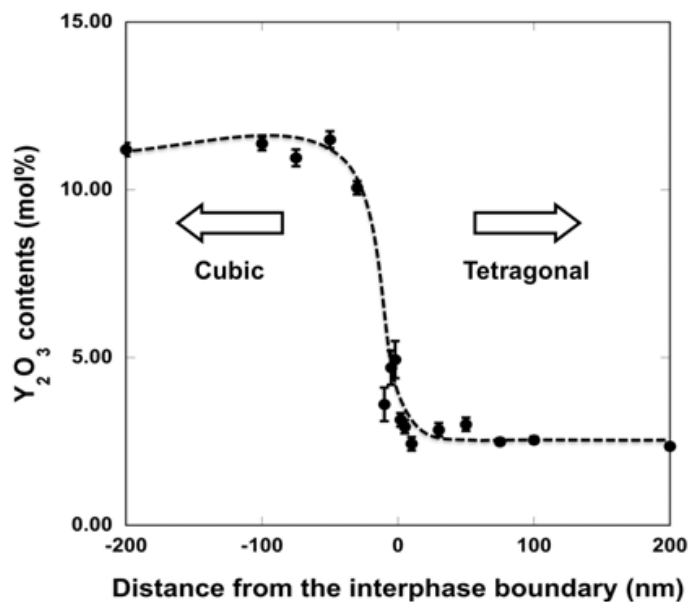


Fig. 12. A  $Y_2O_3$  contents profile obtained by EDS spectra across the c/t interphase boundary as a function of the distance from the boundary.

#### 4. Conclusion

In this chapter, the principles of EDS are briefly described and some results of the nanoscale chemical analysis at many interfaces measured by EDS installed to TEM with field emission

type electron gun, whose probe size is less than less than 1nm. In the bonding interface in the explosively welded Al/Si<sub>3</sub>N<sub>4</sub> clad materials, element distribution around the interface was measured by TEM and STEM-EDS as well as microscopic characterization. For this purpose, TEM and STEM observation revealed that the intermediate layer with approximately 2.5 μm between the Al and Si<sub>3</sub>N<sub>4</sub> exists and this layer consists of fine grains whose average diameter of 100nm. And the intermediate layer consists of only Al from selected area electron diffraction pattern and EDS measurement across the interface. Consequently, we clarified that the fine grained Al is formed by rapid solidification after melting during the cladding and it plays as an important role to the welding of Al and Si<sub>3</sub>N<sub>4</sub>. On the other hand, the microstructures of Y<sub>2</sub>O<sub>3</sub> doped ZrO<sub>2</sub> nano particles were also observed by HRTEM and the distribution of Y<sub>2</sub>O<sub>3</sub> inside particle was measured by EDS. The experimental technique for the observation of whole particle with the size of several 100 nm was developed and the surface segregation of Y<sub>2</sub>O<sub>3</sub> was detected within a few nm from the surface for the relaxation of the excess surface energy. The interphase boundary between the front of grown cubic and tetragonal matrix in sintered Y-TZP was investigated by CTEM and HRTEM with EDS measurement. Y<sup>3+</sup> cation concentration is drastically changed at the c/t interphase boundary. Since the periodic misfit dislocations are also observed at the c/t interphase boundary, therefore, the steep change in Y<sup>3+</sup> cation composition must cause the misfit strain at the interphase boundary, and consequently leads to introduce misfit dislocations. These results will provide the effectivity of the EDS measurement combined with TEM for the chemical analysis of advanced materials on the nano scale and the guidelines for understanding the correlation between the microstructure observation and the nano scale analysis.

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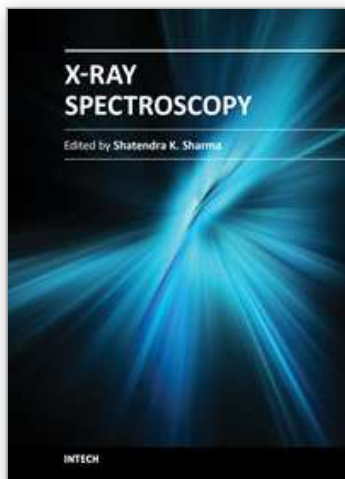
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## **X-Ray Spectroscopy**

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The x-ray is the only invention that became a regular diagnostic tool in hospitals within a week of its first observation by Roentgen in 1895. Even today, x-rays are a great characterization tool at the hands of scientists working in almost every field, such as medicine, physics, material science, space science, chemistry, archeology, and metallurgy. With vast existing applications of x-rays, it is even more surprising that every day people are finding new applications of x-rays or refining the existing techniques. This book consists of selected chapters on the recent applications of x-ray spectroscopy that are of great interest to the scientists and engineers working in the fields of material science, physics, chemistry, astrophysics, astrochemistry, instrumentation, and techniques of x-ray based characterization. The chapters have been grouped into two major sections based upon the techniques and applications. The book covers some basic principles of satellite x-rays as characterization tools for chemical properties and the physics of detectors and x-ray spectrometer. The techniques like EDXRF, WDXRF, EPMA, satellites, micro-beam analysis, particle induced XRF, and matrix effects are discussed. The characterization of thin films and ceramic materials using x-rays is also covered.

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